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	Application No.	Applicant(s)	
Notice of Allowability	10/715,248 Examiner	BROWN, NATHAN Art Unit	R.
•	David B. Thomas	3723	
The MAILING DATE of this communication ap		correspondence addr	ess
All claims being allowable, PROSECUTION ON THE MERITS Interewith (or previously mailed), a Notice of Allowance (PTOL-8 NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT of the Office or upon petition by the applicant. See 37 CFR 1.3	IS (OR REMAINS) CLOSED in this a so or other appropriate communication RIGHTS. This application is subject	pplication. If not includ on will be mailed in due	ed course. THIS
1. X This communication is responsive to the arguments filed	l August 16, 2004.	J	
2. ⊠ The allowed claim(s) is/are <u>1-21</u> .			
3. $igtie$ The drawings filed on <u>17 November 2003</u> are accepted l	by the Examiner.		
 Acknowledgment is made of a claim for foreign priority a) ☐ All b) ☐ Some* c) ☐ None of the: 	under 35 U.S.C. § 119(a)-(d) or (f).		
 Certified copies of the priority documents had 			
2. Certified copies of the priority documents ha			ation from the
3. Copies of the certified copies of the priority of	documents have been received in this	s national stage applica	ation trom the
International Bureau (PCT Rule 17.2(a)).			
* Certified copies not received:			
Applicant has THREE MONTHS FROM THE "MAILING DATI noted below. Failure to timely comply will result in ABANDON THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.	E" of this communication to file a repl NMENT of this application.	y complying with the re	quirements
 A SUBSTITUTE OATH OR DECLARATION must be sub INFORMAL PATENT APPLICATION (PTO-152) which g 	omitted. Note the attached EXAMINE gives reason(s) why the oath or declar	R'S AMENDMENT or Nation is deficient.	NOTICE OF
6. CORRECTED DRAWINGS (as "replacement sheets") m	nust be submitted.		
(a) including changes required by the Notice of Draftspo	erson's Patent Drawing Review (PT0	0-948) attached	
1) 🗌 hereto or 2) 🔲 to Paper No./Mail Date	·		
(b) including changes required by the attached Examine Paper No./Mail Date	er's Amendment / Comment or in the	Office action of	
Identifying indicia such as the application number (see 37 CFF each sheet. Replacement sheet(s) should be labeled as such i	R 1.84(c)) should be written on the drawn the header according to 37 CFR 1.12	vings in the front (not th I(d).	e back) of
 DEPOSIT OF and/or INFORMATION about the department of the department of	posit of BIOLOGICAL MATERIAL IT FOR THE DEPOSIT OF BIOLOGI	must be submitted. CAL MATERIAL.	Note the
Attachment(s)	E □ Notice of Informal	Potent Application /PT	·∩ 152\
 Notice of References Cited (PTO-892) D Notice of Draftperson's Patent Drawing Review (PTO-948) 	5. ☐ Notice of Informal 3) 6. ☐ Interview Summär		0-132)
	Paper No./Mail D	ate	
3. ☑ Information Disclosure Statements (PTO-1449 or PTO/SI Paper No./Mail Date 5/17/04			owanco
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		David B. Thomas Patent Examiner Art Unit 3723	

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NOTICE OF ALLOWANCE

Response to Arguments

1. Applicant's arguments, see pages 2-5, filed August 16, 2004, with respect to the Double Patenting Rejection, and the Obviousness rejection over Leach have been fully considered and are persuasive. The rejection of claims 1-21 has been withdrawn.

Allowable Subject Matter

- Claims 1-21 are allowed.
- 3. The following is an examiner's statement of reasons for allowance: the present invention relates to apparatus that selectively apply different amounts of pressure to different locations on the backsides of semiconductor device structures as one or more layers on the opposite, active surfaces thereof are polished or planarized. It is the examiner's opinion that the prior art of record considered as a whole, alone or in combination, neither anticipates nor renders obvious system for polishing a semiconductor device structure, comprising: a metrology component; a support structure configured to receive the semiconductor device structure; a pressurization component including a plurality of independently movable pressurization structures and actuators corresponding to each of the plurality of pressurization structures, the actuators each being configured to bias a corresponding pressurization structure against a backside of the semiconductor device structure with a selected amount of force, and a polishing component, together in combination with the rest of the limitations in the independent claim.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably

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accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Any inquiry concerning this communication or earlier communications from the examiner should be directed to David B. Thomas whose telephone number is (703) 308-4250. The examiner can normally be reached on 7-4 M-F.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Joseph J. Hail can be reached on (703) 308-2687. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

David B. Thomas Patent Examiner Art Unit 3723